L Number	Hits	Search Text	DB	Time stamp	
15	318	438/623.ccls.	USPAT;	2002/04/05	
			US-PGPUB	16:37	
16	7010	"etch stop" or "etching stop" or "etch stopper"	USPAT;	2002/04/05	
			US-PGPUB	17:16	
17	49132	photoresist	USPAT;	2002/04/05	
	(("-t-b -t" "-t-bing ston" on "otob stonnon") with	US-PGPUB USPAT;	† 17:16 † 2002/04/05	
18	643	("etch stop" or "etching stop" or "etch stopper") with photoresist	US-PGPUB	16:39	
19	12	438/623.ccls. and (("etch stop" or "etching stop" or "etch	USPAT;	2002/04/05	
	12	stopper") with photoresist)	US-PGPUB	16:41	
20	44	438/623.ccls. and ("etch stop" or "etching stop" or "etch	USPAT;	2002/04/05	
	44	stopper") and photoresist	US-PGPUB	16:41	
21	32	(438/623.ccls. and ("etch stop" or "etching stop" or "etch	USPAT;	2002/04/05	
	0_	stopper") and photoresist) not (438/623.ccls. and (("etch stop"	US-PGPUB	16:46	
		or "etching stop" or "etch stopper") with photoresist))	!	•	
22	752	438/624.ccls.	USPAT;	2002/04/05	
			US-PGPUB	16:46	
23	52	(("etch stop" or "etching stop" or "etch stopper") with	USPAT;	2002/04/05	
		photoresist) and 438/624.ccls.	US-PGPUB	16:54	
24	137	("etch stop" or "etching stop" or "etch stopper") and	, USPAT;	2002/04/05	
9 8		photoresist and 438/624.ccls.	US-PGPUB	16:54	
25	85	(("etch stop" or "etching stop" or "etch stopper") and	USPAT:	2002/04/05	
		photoresist and 438/624.ccls.) not ((("etch stop" or "etching	US-PGPUB	16:55	
		stop" or "etch stopper") with photoresist) and 438/624.ccls.)	USPAT;	2002/04/05	
26	39	((("etch stop" or "etching stop" or "etch stopper") and	US-PGPUB	,	
		photoresist and 438/624.ccls.) not ((("etch stop" or "etching stop" or "etch stopper") with photoresist) and 438/624.ccls.))	US-FGFUB	16:59	
		and damascene	i	1	
07	223	438/634.ccls.	USPAT;	· 2002/04/05	
27	223	430/034.ccis.	US-PGPUB	17:00	
28	56	(("etch stop" or "etching stop" or "etch stopper") with	USPAT;	2002/04/05	
20	J.	photoresist) and 438/634.ccls.	US-PGPUB	17:05	
29	308	438/638.ccls.	· USPAT;	2002/04/05	
		10-7-0	US-PGPUB	, 17:05	
30	47	(("etch stop" or "etching stop" or "etch stopper") with	USPAT;	2002/04/05	
		photoresist) and 438/638.ccls.	US-PGPUB	17:09	
31	1049	438/637.ccls.	USPAT;	2002/04/05	
			US-PGPUB	17:10	
32	84	(("etch stop" or "etching stop" or "etch stopper") with	USPAT;	2002/04/05	
		photoresist) and 438/637.ccls.	US-PGPUB	17:13	
33	362	438/725.ccls.	USPAT;	2002/04/05	
		(("etch stop" or "etching stop" or "etch stopper") with	US-PGPUB USPAT;	· 17:13 2002/04/05	
34	14	photoresist) and 438/725.ccls.	US-PGPUB	17:14	
	106	438/952.ccls.	USPAT;	2002/04/05	
35	100	430/932.003.	US-PGPUB	17:15	
36	3	(("etch stop" or "etching stop" or "etch stopper") with	USPAT;	2002/04/05	
30	,	photoresist) and 438/952.ccls.	US-PGPUB	17:15	
37	1191	438/for.355.ccls.	. EPO; JPO;	2002/04/05	
3/		400,000	DERWENT	17:16	
38	3084	"etch stop" or "etching stop" or "etch stopper"	EPO; JPO;	2002/04/05	
			DERWENT	. 17:16	
39	44654	photoresist	EPO; JPO;	2002/04/05	
-			DERWENT	17:16	
40	3	438/for.355.ccls. and ("etch stop" or "etching stop" or "etch	EPO; JPO;	2002/04/05	
41		stopper")	DERWENT	17:16	
	1006	damascene	EPO; JPO;	2002/04/05	
		0.00	DERWENT	17:16	
42	0	438/for.355.ccls. and damascene	EPO; JPO;	2002/04/05	
44		100 /for 100 orla	DERWENT	17:16	
	272	438/for.489.ccls.	EPO; JPO; DERWENT	2002/04/05 17:17	
		damagana and 400 /for 400 agls	EPO; JPO;	2002/04/05	
45	0	damascene and 438/for.489.ccls.	DERWENT	17:17	

46	0	((("etch stop" or "etching stop" or "etch stopper") with	EPO; JPO;	2002/04/05	
		photoresist) and 438/634.ccls.) and 438/for.489.ccls.	DERWENT	17:17	
47	46	("etch stop" or "etching stop" or "etch stopper") and	EPO; JPO;	2002/04/05	
		photoresist and damascene	DERWENT	17:17	
-	1	("6140226").PN.	' USPAT;	2002/04/04	
			US-PGPUB	15:49	
-	1	("6077769").PN.	USPAT;	2002/04/04	
			US-PGPUB	15:50	
-	484800	organic or polytetrafluoroethylene or "fluorinated polyallyl	USPAT;	2002/04/04	
		ether" or "fluorinated polyimide"	US-PGPUB	15:52	
•	513	(438/618).CCLS.	USPAT;	1 2002/04/04	
			US-PGPUB	15:52	
-	125	(organic or polytetrafluoroethylene or "fluorinated polyallyl	· USPAT;	1 2002/04/04	
		ether" or "fluorinated polyimide") and ((438/618).CCLS.)	US-PGPUB	15:53	
-	5782	"etch stop"	USPAT;	' 2002/04/04	
			US-PGPUB	15:53	
-	29	((organic or polytetrafluoroethylene or "fluorinated polyallyl	USPAT;	2002/04/04	
		ether" or "fluorinated polyimide") and ((438/618).CCLS.)) and	US-PGPUB	15:53	
		"etch stop"	1		
-	318	438/623.ccls.	USPAT;	2002/04/04	
			US-PGPUB	16:10	
-	1266	(organic or polytetrafluoroethylene or "fluorinated polyallyl	USPAT;	2002/04/04	
		ether" or "fluorinated polyimide") and "etch stop"	US-PGPUB	16:10	
-	31	438/623.ccls. and ((organic or polytetrafluoroethylene or	USPAT;	2002/04/04	
		"fluorinated polyallyl ether" or "fluorinated polyimide") and	US-PGPUB	16:10	
		"etch stop")			